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What is claimed is:

1	1.	A	light-emitting	device	with	reduced	lattice
2	mismatch,	co	mprising:				

- a substrate having a first lattice constant;
- a first buffer multilayer deposited on said substrate, wherein the lattice constant of said first buffer multilayer ranges from said first lattice constant at the bottom of said first buffer multilayer to a second lattice constant at the top of said first buffer multilayer;
- a second buffer multilayer deposited on said first buffer multilayer, wherein the lattice constant of said second buffer multilayer ranges from said second lattice constant at the bottom of said second buffer multilayer to a third lattice constant at the top of said second buffer multilayer; and
- a GaN base epitaxial layer deposited on the surface of said second buffer multilayer with said third lattice.
- 2. The device as claimed in claim 1, wherein said substrate comprises silicon, said first buffer multilayer is represented by general formula $B_xGa_{(1-x)}P$ (where $0.02 \le X \le 1$), and said second buffer multilayer is represented by general formula $In_yGa_{(1-y)}N$ (where $0 \le y \le 0.059$).
- 3. The method as claimed in claim 1, wherein said substrate comprises 3C-SiC, said first buffer multilayer is represented by general formula $B_xGa_{(1-x)}P$ (where X=1),

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and said second buffer multilayer is represented by general formula $In_vGa_{(1-v)}N$ (where 0< y <0.059).

- 4. The method as claimed in claim 1, wherein said substrate comprises GaP, said first buffer multilayer is represented by general formula $B_xGa_{(1-x)}P$ (where $0 \le X \le 1$), and said second buffer multilayer is represented by general formula $In_vGa_{(1-y)}N$ (where 0 < y < 0.059).
- 5. The method as claimed in claim 1, wherein said substrate comprises GaAs, said first buffer multilayer comprises $GaAs_xP_{(1-x)}$ and $B_yGa_{(1-y)}P$ (where $0 \le X \le 1$, $0 \le y \le 1$), and said second buffer multilayer is represented by general formula $In_zGa_{(1-z)}N$ (where $0 \le z \le 0.059$).
- 6. A light-emitting device with reduced lattice mismatch, comprising:
 - a silicon substrate having a first lattice constant;
 - a $B_xGa_{(1-x)}P$ buffer layer deposited on said silicon substrate, wherein the lattice constant of said $B_xGa_{(1-x)}P$ buffer layer ranges from said first lattice constant at the bottom of said $B_xGa_{(1-x)}P$ buffer layer to a second lattice constant at the top of said $B_xGa_{(1-x)}P$ buffer layer;
 - a ${\rm In_yGa_{(1-y)}N}$ buffer layer deposited on said ${\rm B_xGa_{(1-x)}P}$ buffer layer, wherein the lattice constant of the ${\rm In_yGa_{(1-y)}N}$ buffer layer ranges from said second lattice constant at the bottom of said ${\rm In_yGa_{(1-y)}N}$ buffer layer to a third lattice constant at the top of said ${\rm In_yGa_{(1-y)}N}$ buffer layer; and

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a GaN-based epitaxial layer deposited on the InyGa(1-

18	$_{y)}N$ buffer layer with said third lattice
19	constant.
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1	7. A light-emitting device with reduced lattice
2	mismatch, comprising:
3	a 3C-SiC substrate having a first lattice constant;
4	a $B_xGa_{(1-x)}P$ buffer layer deposited on said 3C-SiC
5	substrate, wherein the lattice constant of said
6	$B_xGa_{(1-x)}P$ buffer layer ranges from said first
7	lattice constant at the bottom of said $B_xGa_{(1-x)}P$
8	buffer layer to a second lattice constant at
9	the top of said $B_xGa_{(1-x)}P$ buffer layer;
10	a $\text{In}_y\text{Ga}_{(1-y)}\text{N}$ buffer layer deposited on said $\text{B}_x\text{Ga}_{(1-x)}\text{P}$
11	buffer layer, wherein the lattice constant of
12	said $In_yGa_{(1-y)}N$ buffer layer ranges from said
13	second lattice constant at the bottom of said
14	$In_yGa_{(1-y)}N$ buffer layer to a third lattice
15	constant at the top of said InyGa(1-y)N buffer
16	layer; and
17	a GaN-based epitaxial layer deposited on the In _v Ga ₍₁₋
18	$_{y)}N$ buffer layer with third lattice constant.
1	8. A light-emitting device with reduced lattice
2	mismatch, comprising:
3	a GaAs substrate having a first lattice constant;
4	a $GaAs_xP_{(1-x)}$ buffer layer deposited on said $GaAs$
5	substrate, wherein the lattice constant of said
6	$GaAs_{\mathbf{x}}P_{(1-\mathbf{x})}$ buffer layer ranges from said first
7	lattice constant at the bottom of said GaAs _x P ₍₁₋
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8	x) buffer layer to a second lattice constant at
9	the top of said $GaAs_xP_{(1-x)}$ buffer layer;
10	a $B_yGa_{(1-y)}P$ buffer layer deposited on said $GaAs_xP_{(1-x)}$
11	buffer layer, wherein the lattice constant of
12	said $B_yGa_{(1-y)}P$ buffer layer ranges from said
13	second lattice constant at the bottom of said
14	$B_yGa_{(1-y)}P$ buffer layer to a third lattice
15	constant at the top of said $B_yGa_{(1-y)}P$ buffer
16	layer;
17	a ${\rm In_zGa_{(1-z)}N}$ buffer layer deposited on said ${\rm B_yGa_{(1-y)}P}$
18	buffer layer, wherein the lattice constant of
19	said $\operatorname{In_zGa_{(1-z)}N}$ buffer layer ranges from said
20	third lattice constant at the bottom of said
21	$\text{In}_z\text{Ga}_{(1-z)}N$ buffer layer to a fourth lattice
22	constant at the top of said $In_yGa_{(1-y)}N$ buffer
23	layer; and
24	a GaN-based epitaxial layer deposited on said ${\rm In_zGa_{(1-)}}$
25	$_{z)}N$ buffer layer with said fourth lattice
26	constant.
1	9. A light-emitting device with reduced lattice
2	mismatch, comprising:
3	a GaP substrate having a first lattice constant;
4	a $B_xGa_{(1-x)}P$ buffer layer deposited on said GaP
5	substrate, wherein the lattice constant of said
6	$B_xGa_{(1-x)}P$ buffer layer ranges from said first
7	lattice constant at the bottom of said $B_xGa_{(1-x)}P$
8	buffer layer to a second lattice constant at
9	the top of said $B_xGa_{(1-x)}P$ buffer layer;
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10	a $\text{In}_y\text{Ga}_{(1-y)}N$ buffer layer deposited on said $B_x\text{Ga}_{(1-x)}P$
11	buffer layer, wherein the lattice constant of
12	said $In_yGa_{(1-y)}N$ buffer layer ranges from said
13	second lattice constant at the bottom of said
14	$\text{In}_y\text{Ga}_{(1-y)}N$ buffer layer to a third lattice
15	constant at the top of said $In_yGa_{(1-y)}N$ buffer
16	layer; and
17	a GaN-based epitaxial layer deposited on said $In_yGa_{(1)}$
18	$_{y)}N$ buffer layer with said third lattice
19	constant.